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**Hamada et al.**

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(54) **DISPLAY APPARATUS USING  
ELECTROLUMINESCENCE ELEMENTS AND  
METHOD OF MANUFACTURING THE SAME**

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1997, now Pat. No. 6,114,183.

#### (30) Foreign Application Priority Data

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(52) **U.S. Cl.** ..... **257/88**; 257/40; 257/72;  
313/501; 313/505

(58) **Field of Search** ..... 257/40, 59, 72,  
257/88, 103; 349/39, 56; 313/501, 505

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*Primary Examiner*—Matthew Smith

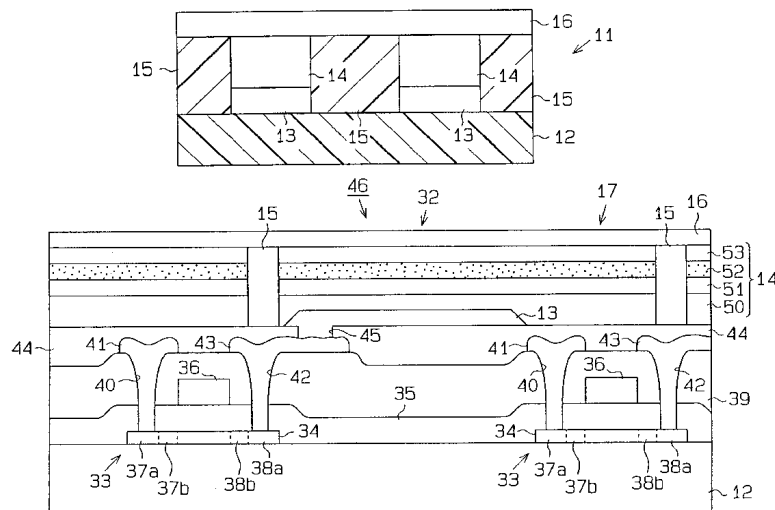
*Assistant Examiner*—Lex H. Malsawma

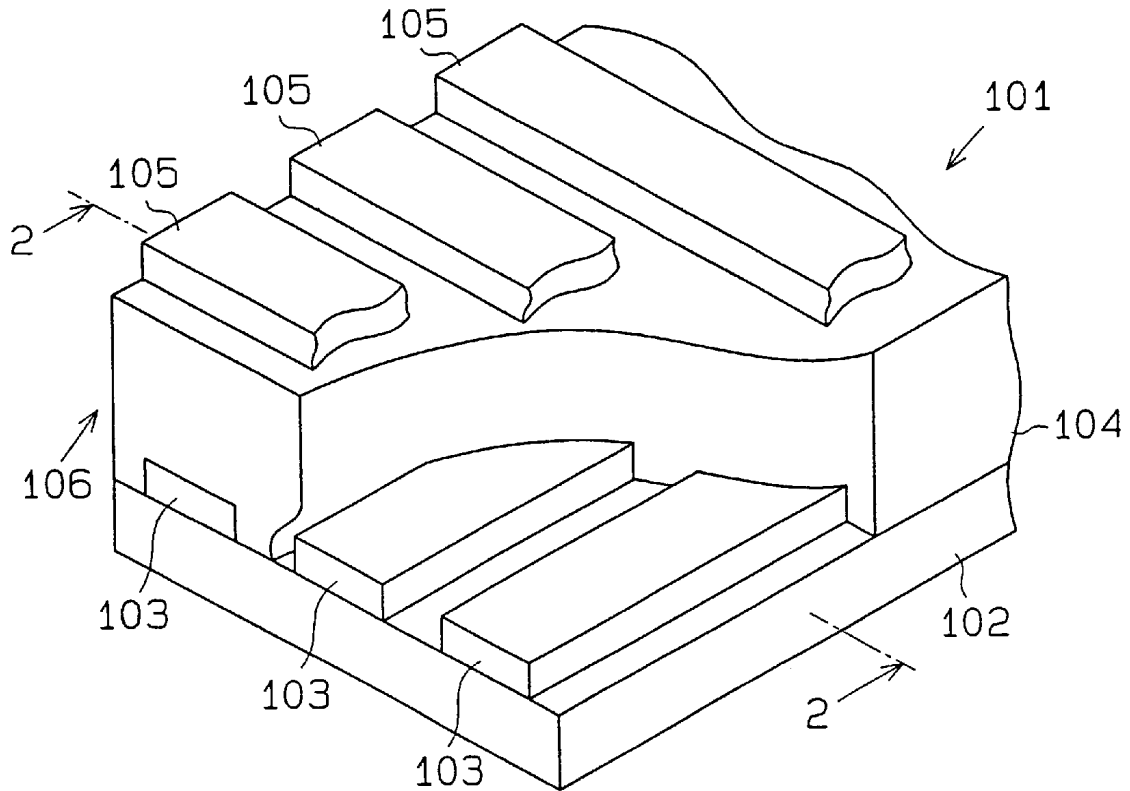
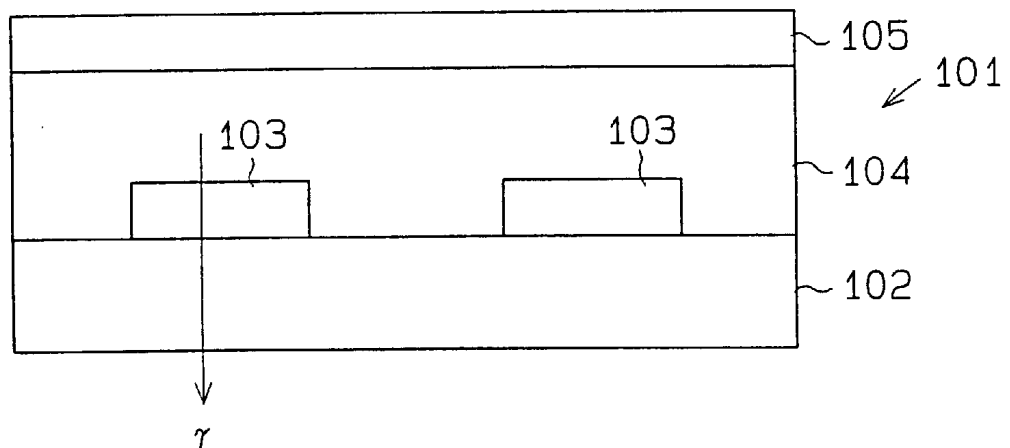
(74) *Attorney, Agent, or Firm*—Sheridan Ross P.C.

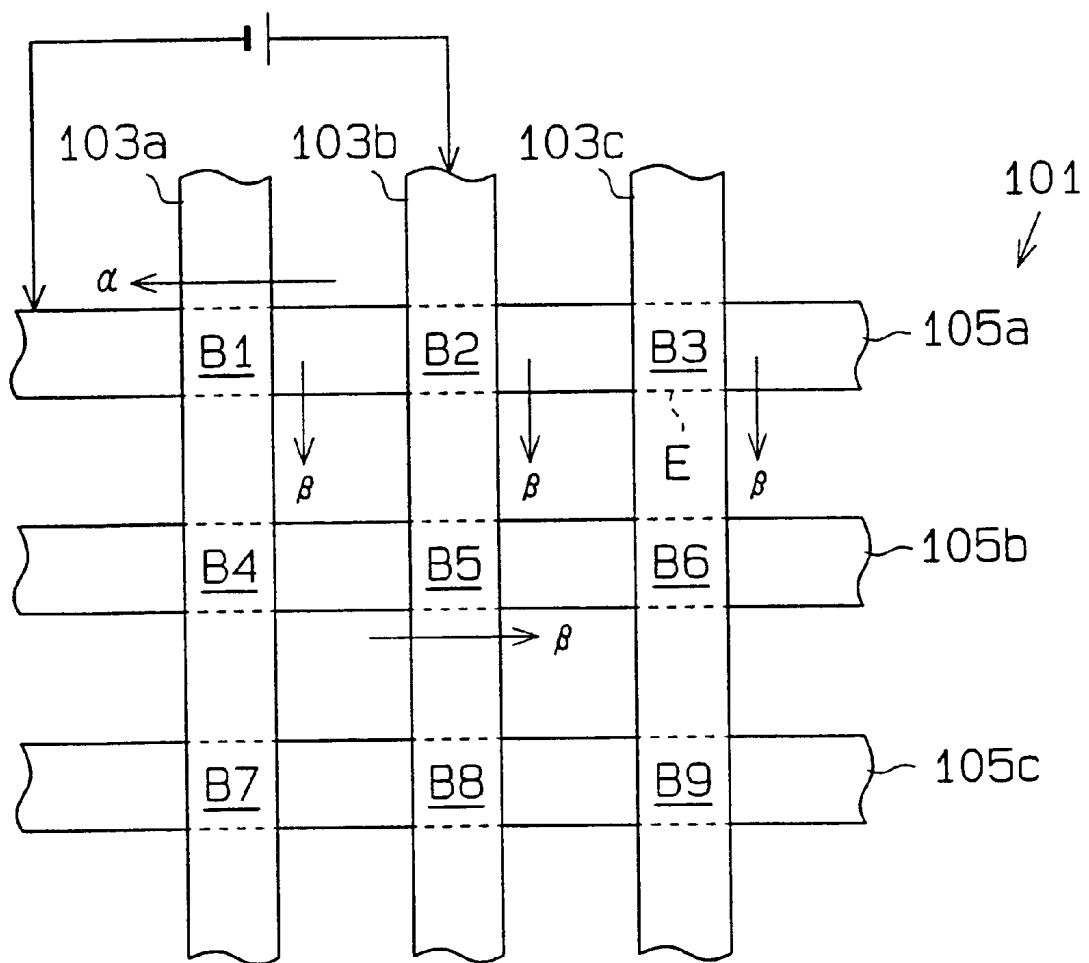
#### (57) ABSTRACT

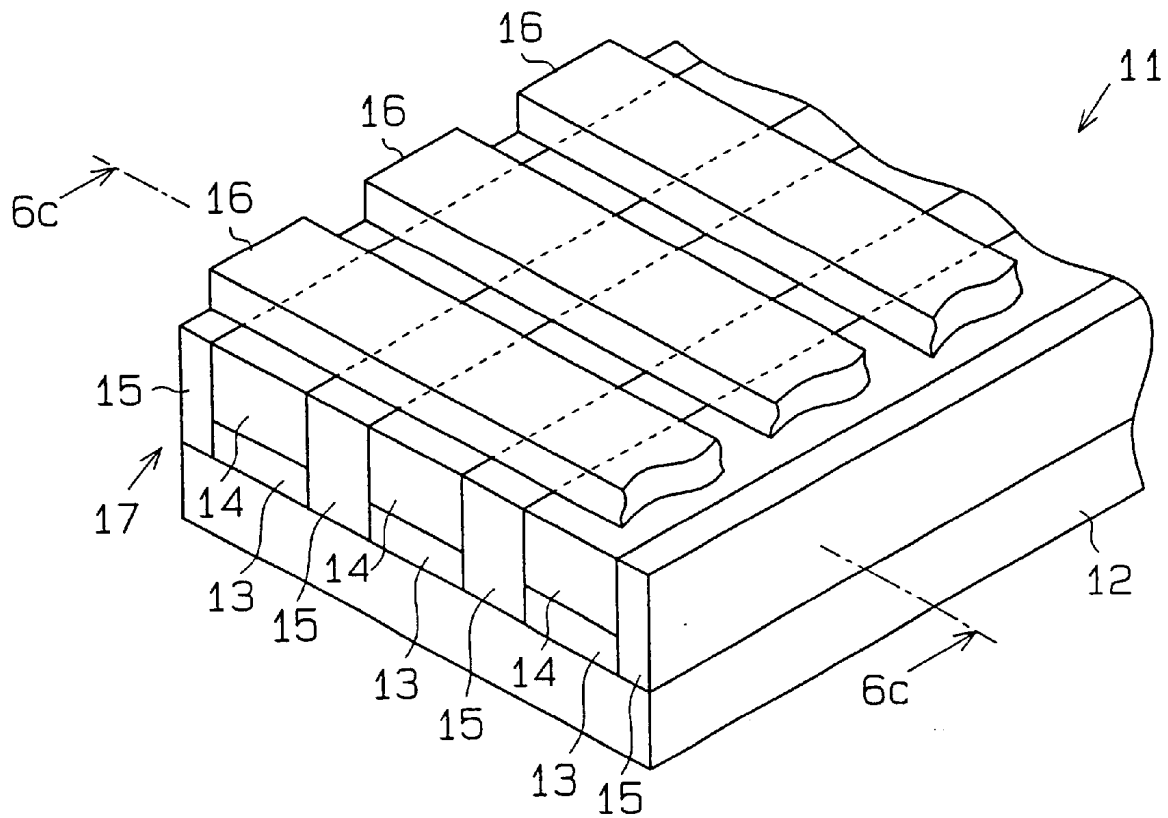
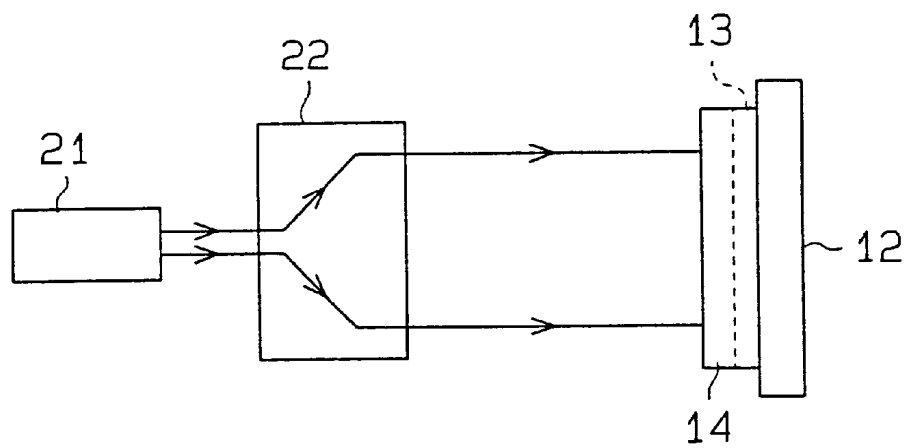
A display apparatus having electroluminescence (EL) elements includes a light emitting layer for generating light. A high energy laser beam is irradiated on the luminous element layer to define a plurality of regions of the light emitting layer. A plurality of first electrodes are arranged generally parallel to each other over a first surface of the light emitting layer and a plurality of second electrodes are arranged generally parallel to one another and perpendicular to the first electrodes on a second, opposite surface of the light emitting. The EL elements are formed at the intersections of the first and second electrodes.

**34 Claims, 8 Drawing Sheets**

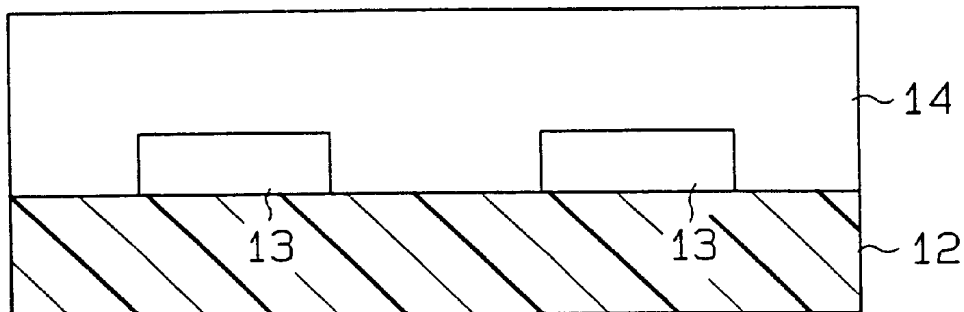


**Fig.1 (PRIOR ART)****Fig.2 (PRIOR ART)**

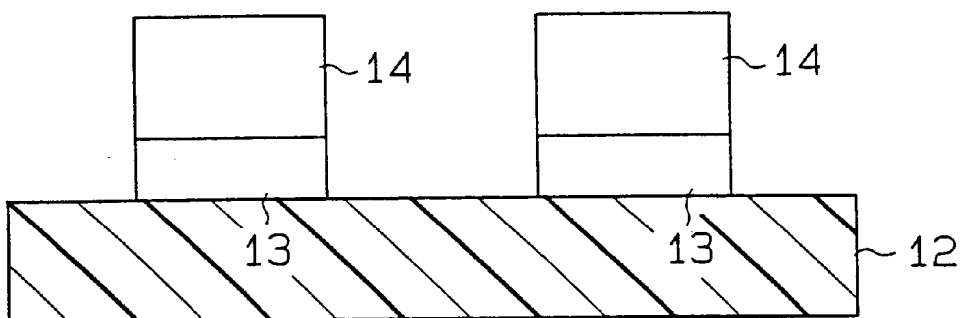
**Fig.3 (PRIOR ART)**

**Fig. 4****Fig. 5**

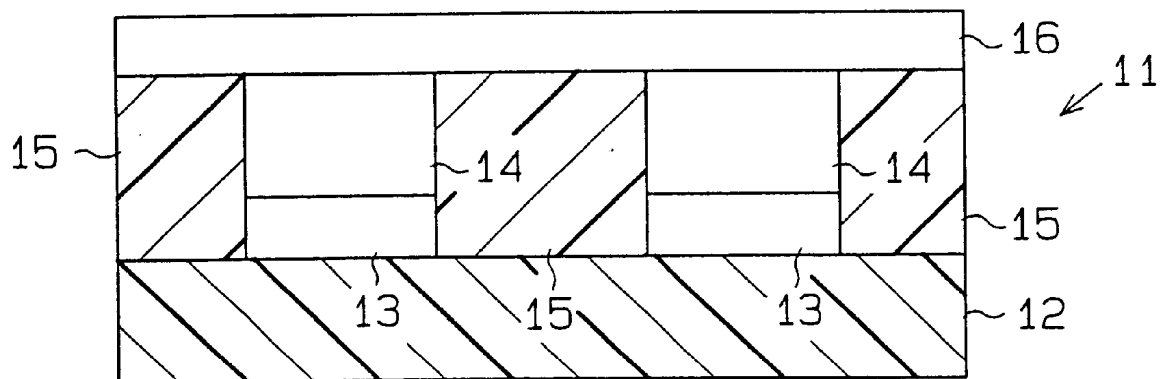
**Fig. 6 (a)**

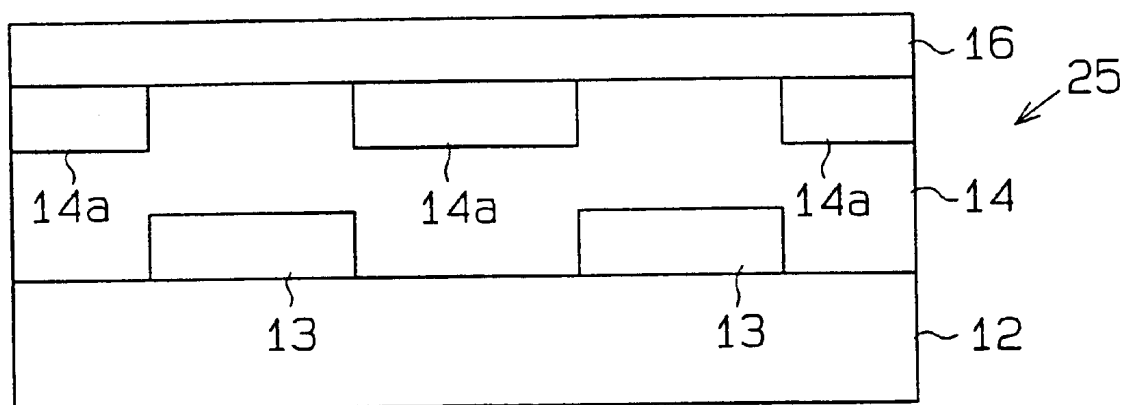


**Fig. 6 (b)**

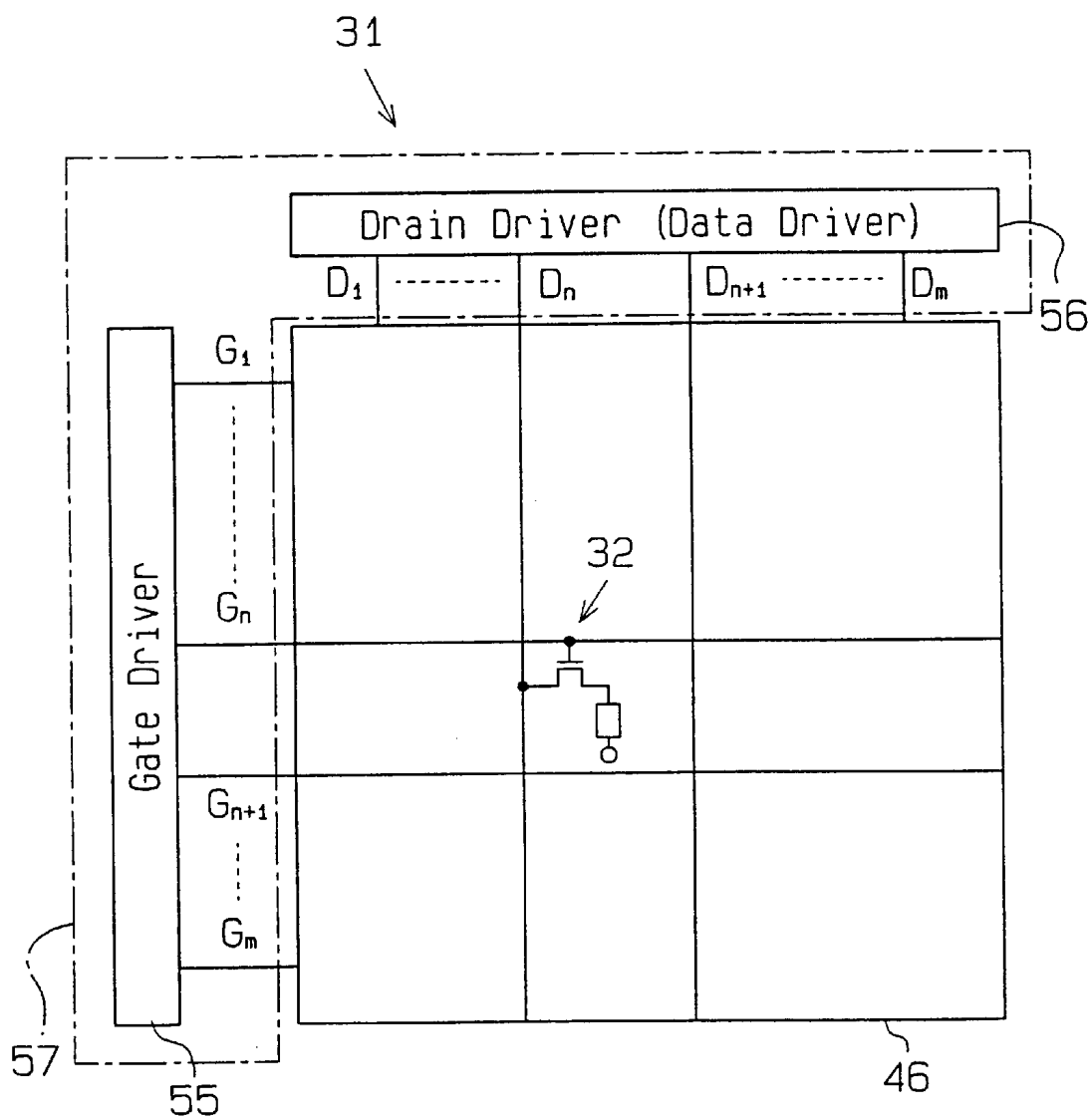


**Fig. 6 (c)**

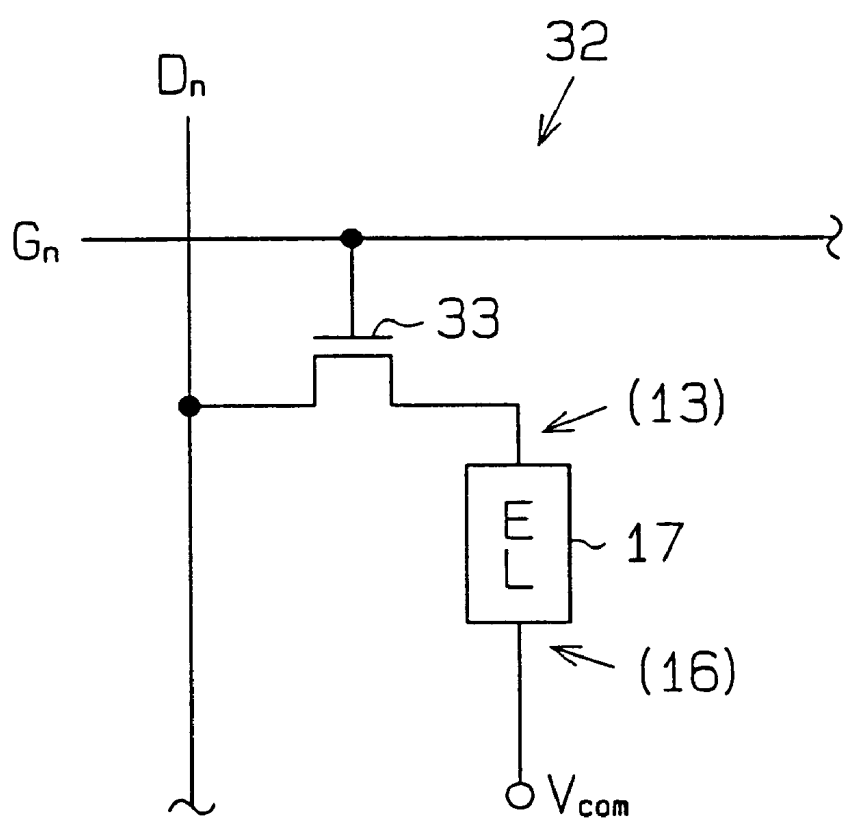


**Fig. 7**



**Fig. 9**



**Fig. 10**

# DISPLAY APPARATUS USING ELECTROLUMINESCENCE ELEMENTS AND METHOD OF MANUFACTURING THE SAME

This application is a divisional of application Ser. No. 08/987,460 filed on Dec. 9, 1997 now U.S. Pat. No. 6,114,183.

## BACKGROUND OF THE INVENTION

The present invention relates to a display apparatus using electroluminescence elements, and a method of manufacturing the display apparatus.

Electroluminescence (EL) elements for use in a display apparatus include an inorganic EL element and an organic EL element. The inorganic EL element uses a thin film of an inorganic compound, like zinc selenide or zinc sulfide, as a fluorescent material, and the organic EL element uses an organic compound as a fluorescent material. Preferably, the organic EL element has the following features:

- (1) A high external quantum efficiency.
- (2) Light is emitted on a low driving voltage.
- (3) Multifarious colors (green, red, blue, yellow, etc.) can be generated by selecting a proper fluorescent material.
- (4) The display is clear and no back light is needed.
- (5) There is no dependency on the viewing angle.
- (6) The organic EL element is thin and light.
- (7) A soft material like a plastic film can be used for the substrate.

Due to the aforementioned features, a display apparatus using such an organic EL elements (hereinafter referred to as "organic EL display apparatus") is a desirable replacement for a CRT or liquid crystal display.

An organic EL display apparatus employs a dot matrix system which displays an image with dots arranged in a matrix form. The dot matrix system includes a simple matrix system or an active matrix system.

The simple matrix system directly drives organic EL elements of a matrix of pixels, arranged on a display panel, in synchronism with a scan signal using an external driving unit. Each pixel on the display panel has only an organic EL element. As the number of scan lines of a display apparatus increases, therefore, the driving time (duty) assigned to each pixel decreases. This reduces the contrast as well as the luminance intensity of the display screen.

In the active matrix system, each of pixels arranged in a matrix form has an organic EL element and a pixel driving element (active elements). The pixel driving element serves as a switch which is switched on or off by the scan signal. A data signal (display signal, video signal) is transmitted to the anode of the associated organic EL element via an enabled pixel driving element. As the data signal is written in the organic EL element, the organic EL element is driven. Even when the pixel driving element is switch off state, the data signal previously applied to the anode of the organic EL element is held, in the form of a charge, in the organic EL element. The organic EL element is kept driven until the associated pixel driving element is switched on again. Even if the driving time per pixel driving element decreases as the number of scan lines is increased, therefore, the driving of the organic EL elements is not affected. Specifically, a sufficient luminance intensity is secured for an image to be displayed on the display panel and reduction in the contrast is prevented. The active matrix system can therefore provide display images with a higher quality than the simple matrix system.

Depending on the difference in pixel driving elements, display apparatuses of the active matrix system are classified into a transistor type (three-terminal type) and a diode type (two-terminal type). The transistor type is more difficult to manufacture than the diode type. On the other hand, the contrast and resolution of images which are displayed by the transistor type display apparatus can be improved easily. Therefore, the transistor type display apparatus provides high-quality images which match with those displayed by a CRT display. The following description on the operational principle of the active matrix system is mainly associated with the transistor type.

A conventional organic EL display apparatus **101** of the simple matrix system will now be discussed with reference to FIGS. 1 through 3.

As shown in FIG. 1, a plurality of anodes **103** are arranged, parallel to one another, on an insulator substrate **102**, and a light emitting layer **104** is provided on the insulator substrate **102** to cover the anodes **103**. A plurality of cathodes **105** are arranged, parallel to one another, on the light emitting layer **104**. The anodes **103** are placed perpendicular to the cathodes **105**. The light emitting layer **104**, the anodes **103** and the cathodes **105** form an organic EL element **106**. The insulator substrate **102** is preferably made of transparent glass, synthetic resin or the like. The anodes **103** are preferably formed of transparent electrodes of ITO (Indium Tin Oxide) or the like. The light emitting layer **104** is preferably formed of an organic compound. The cathodes **105** are preferably formed of a magnesium-indium alloy.

In the organic EL element **106**, holes coming from the anodes **103** are recombined with electrons coming from the cathodes **105** inside the light emitting layer **104**, emitting light. The light is emitted outside via the anodes **103** and the transparent insulator substrate **102** as indicated by the arrow  $\gamma$  in FIG. 2.

FIG. 3 is a schematic plan view of the organic EL display apparatus **101**, as viewed from the anodes **103**. In FIG. 3, only the anodes **103** and the cathodes **105** are illustrated.

Defined at the individual intersections of anodes **103a** to **103c** and cathodes **105a** to **105c** are light emitting areas **B1** to **B9** which emit light, as discussed above. That is, the light emitting areas **B1**–**B9**, arranged in a matrix form, form the organic EL display apparatus **101**.

In the simple matrix system, the positive terminal of a driving power supply is connected to one anode **103**, and the negative terminal of the driving power supply is connected to the corresponding cathode **105**. In this manner, the anode **103** and the cathode **105** are energized.

In order for light emitting area **B2** at the intersection of the anode **103b** and the cathode **105a** to emit light, for example, the positive terminal is connected to the anode **103b** and the negative terminal is connected to the cathode **105a**, and power is supplied through the terminals. As a result, a forward current flows, as indicated by the arrow  $\alpha$ .

Since the light emitting layer **104** is provided on the insulator substrate **102** so as to cover a plurality of anodes **103**, a leak current flows, as indicated by the arrow  $\beta$ . The leak current energizes not only the light emitting area **B2**, but also the light emitting areas **B1**, **B3** and **B5** near the light emitting area **B2**. As a result, the light emitting areas **B1**, **B3** and **B5** emit light. This phenomenon is called an optical crosstalk caused by the leak current characteristic of the EL element **106**. This shortcoming is inherent not only to the simple matrix system but also to the active matrix system and occurs in an inorganic EL display apparatus as well as an organic EL display apparatus.

The optical crosstalk deteriorates the contrast of images displayed by the organic EL display apparatus **101**, disabling

the acquisition of high-definition images. Particularly, a full-color organic EL display apparatus using EL elements causes color "smearing" and does not provide clear images.

Japanese Unexamined Patent Publication No. Hei 4-249095 discloses an EL element which prevents the occurrence of such a crosstalk as a solution to the aforementioned problem. In the EL element, a plurality of light emitting elements each comprised of an organic compound are provided apart from one another between a transparent electrode and a plurality of metal electrodes. Since the individual light emitting elements in the EL element are provided apart from one another, a crosstalk originating from the leak current does not occur. This makes an image to be displayed clearer.

As light emitting elements are made of an organic compound, they have poor water resistance. Therefore, the photolithography technology which uses cleaning water cannot be used in separating light emitting elements. The individual EL elements are thus formed directly using a metal mask. The use of the metal mask restricts the micro work of light emitting elements and gets in the way of improving the clearness of display images.

Accordingly, it is an object of the present invention to provide a display apparatus capable of displaying clear images and a method of manufacturing the same.

#### SUMMARY OF THE INVENTION

Briefly stated, the present invention provides a method of manufacturing a display apparatus, comprising the steps of: providing a light emitting layer for generating light; and irradiating a high-energy beam on said light emitting layer to define said light emitting layer into a plurality of regions.

The present invention further provides a method of manufacturing a display apparatus, comprising the steps of: providing a plurality of first electrodes generally parallel to one another; forming a light emitting layer for generating light on said first electrodes; irradiating said light emitting layer with a high-energy beam to define said light emitting layer into a plurality of regions; and forming a second electrode on said defined regions of said light emitting layer.

The present invention provides a method of manufacturing a display apparatus comprising the steps of: providing a plurality of first electrodes which extends generally parallel to one another; forming a light emitting layer of an organic compound for generating light on said first electrodes; irradiating said light emitting layer with a laser beam to define said light emitting layer into a plurality of regions; and forming a plurality of second electrodes on said defined regions of said light emitting layer which extend generally parallel to one another and generally perpendicular to said first electrodes.

The present invention further provides a display apparatus of an active matrix system comprising: a light emitting layer having a first surface and a second surface opposite to said first surface and defined into a plurality of regions; a plurality of first electrodes arranged, generally parallel to one another, over said first surface of said light emitting layer; a plurality of second electrodes arranged, generally parallel to one another and intersecting said first electrodes, over said second surface of said light emitting layer; electroluminescence elements formed at individual intersections of said first electrodes and said second electrodes; and driving elements, arranged in association with said electroluminescence elements, for driving the associated electroluminescence elements.

Other aspects and advantages of the invention will become apparent from the following description, taken in

conjunction with the accompanying drawings, illustrating by way of example the principles of the invention.

#### BRIEF DESCRIPTION OF THE DRAWINGS

The invention, together with objects and advantages thereof, may best be understood by reference to the following description of the presently preferred embodiments together with the accompanying drawings.

FIG. 1 is a perspective view showing a conventional organic EL display apparatus;

FIG. 2 is a cross-sectional view taken along the line 2—2 in FIG. 1;

FIG. 3 is a plan view showing only the electrodes of the display apparatus of FIG. 1;

FIG. 4 is a perspective view of an organic EL display apparatus according to a first embodiment of the invention;

FIG. 5 is a schematic diagram illustrating a manufacturing step of the display apparatus of FIG. 4;

FIG. 6A is a cross-sectional view of the display apparatus showing a first manufacturing step;

FIG. 6B is a cross-sectional view of the display apparatus showing a second manufacturing step;

FIG. 6C is a cross-sectional view of the display apparatus taken along the line 4c—4c in FIG. 4, showing a third manufacturing step;

FIG. 7 is a cross-sectional view of an organic EL display apparatus according to a second embodiment of the present invention;

FIG. 8 is a cross-sectional view of an organic EL display apparatus according to a third embodiment of the present invention;

FIG. 9 is a block diagram illustrating the organic EL display apparatus of FIG. 8; and

FIG. 10 is a schematic circuit diagram of an equivalent circuit showing a pixel of the organic EL display apparatus of FIG. 8.

#### DETAILED DESCRIPTION OF THE PREFERRED EMBODIMENTS

In the drawing, like numerals are used for like elements throughout.

##### First Embodiment

A display apparatus according to the first embodiment of the present invention will now be described with reference to FIGS. 4 through 6.

As shown in FIG. 4, an organic EL display apparatus 11 of the simple matrix system includes a transparent insulator substrate 12 of glass or a synthetic resin. A plurality of anodes 13 are formed generally parallel to one another on the substrate 12. The anodes 13 are formed of transparent electrodes preferably of ITO (Indium Tin Oxide). Light emitting layers 14 of an organic compound are respectively formed on the anodes 13.

A passivation layer 15 preferably made of SOG (Spin On Glass), is located in each space on the insulator substrate 12 between the adjoining light emitting layers 14. The individual passivation layers 15 define the light emitting layers 14 and isolate adjacent light emitting layers 14.

A plurality of band-like cathodes 16 of a magnesium-indium alloy are formed on the passivation layers 15 and the light emitting layers 14 and extend generally parallel to one another. The individual cathodes 16 extend in a direction

generally perpendicular to the anodes **13**, the light emitting layers **14** and the passivation layers **15**. An organic EL element **17** comprises the light emitting layers **14**, the anodes **13** and the cathodes **16**.

The manufacturing process of the organic EL display apparatus **11** will now be described.

As shown in FIG. 6A, the individual anodes **13** are formed on the insulator substrate **12**, preferably by using sputtering, electron beam vapor deposition, atmospheric thermal CVD, spraying, dipping or plasma CVD. The light emitting layers **14** are formed on the insulator substrate **12** to cover the individual anodes **13** using electron beam vapor deposition. It is preferable that the anodes **13** to have a uniform thickness.

Then, a high-energy laser beam is irradiated such that a first portion of the light emitting layer **14** is located on each associated anode **13** and a second portion of the light emitting layer **14**, excluding the first portion, is removed, as shown in FIG. 6B. As a result, the second portion of each light emitting layer **14** is removed, leaving the first portion of the light emitting layer **14** on the associated anode **13**. The light emitting layers **14** on the respective anodes **13** are thus formed, preferably substantially parallel to one another, along the anodes **13**.

The laser beam is irradiated as shown in FIG. 5. The laser beam, emitted from a laser device **21**, enters a beam expander **22**. In this embodiment, a KrF excimer laser having a wavelength of 248 nm is used. The laser beam has an irradiation area of 10 mm×10 mm and energy of 600 mJ/cm<sup>2</sup>. The laser beam is not limited to this particular one. For example, an ArF excimer laser with a wavelength of 193 nm, XeCl excimer laser with a wavelength of 308 nm, XeF excimer laser with a wavelength of 351 nm, copper vapor laser with a wavelength of 578 nm, Ar laser with a wavelength of 515 nm, the second harmonic of a YAG laser with a wavelength of 530 nm, or the like may be used as well. The light emitting layers **14** may be scanned with a laser beam directly to be removed or reformed without using the beam expander **22**. To implement a uniform work, it is desirable to use a laser beam which has a certain, constant energy distribution characteristic. Further, an electron beam or ion-beam may be used in place of a high-energy laser beam.

The laser beam incident to the beam expander **22** is enlarged in the form of a thin slit, which increases the irradiation area of the laser beam. The beam expander **22** preferably comprises a pair of cylindrical lenses. The energy of the enlarged laser beam ranges from 10 to 500 mJ/cm<sup>2</sup>. As the laser beam hits the second portion of each light emitting layer **14** between the anodes **13**, the second portion is linearly and collectively removed.

Then, the passivation layer **15**, preferably of SOG, is formed between the adjoining light emitting layers **14**, as shown in FIG. 6C. Then, the electrode layer, preferably of a magnesium-indium alloy, is formed uniformly and in a uniform thickness on the passivation layers **15** and the light emitting layers **14** preferably by electron beam vapor deposition. The electrode layer is cut by the aforementioned laser beam to form a plurality of cathodes **16**, which run generally perpendicular to the anodes **13**.

In the organic EL element **17** with the above-described structure, the holes coming from each anode **13** are recombined with the electrons coming from the associated cathode **16** inside the associated light emitting layer **14**, and light is emitted outside from the transparent anode **13** via the transparent substrate **12**. At this time, each light emitting layer **14** is defined and isolated by the passivation layers **15**

so that no leak current flows from one light emitting layer **14** to another, which prevents the occurrence of a crosstalk and improves the clearness of displayed images.

The present embodiment uses a laser beam to define the light emitting layers **14**. The use of the laser beam facilitates the manufacturing process of the organic EL element **17** which is free of a crosstalk. Further, the use of the laser beam permits the fine removal of the second portions of the light emitting layers **14**. Such micro work allows the organic EL element **17** having a high resolution to be manufactured.

### Second Embodiment

The second embodiment of this invention will be discussed below referring to FIG. 7.

In an organic EL display apparatus **25** according to the second embodiment, after a plurality of anodes **13** are formed on an insulator substrate **12**, a light emitting layer **14** having a uniform thickness is formed on the substrate **12** to cover the anodes **13**. A high-energy laser beam is locally irradiated on (second) portions of the light emitting layer **14**, excluding first portions thereof on the anodes **13**. The irradiated second portions are reformed to high-resistance portions **14a** by the heat. The light emitting layer **14** is thus defined into a plurality of areas by the high-resistance portions **14a**. In other words, the high-resistance portions **14a** define the light emitting layer **14** on the associated anodes **13**.

Then, a plurality of cathodes **16** are formed generally perpendicular to the anodes **13** on the light emitting layer **14** and the high-resistance portions **14a**.

In the organic EL display apparatus **25** of the second embodiment, as per the first embodiment, the light generated by the light emitting layer **14** goes outside through the anodes **13** and the substrate **12**. At this time, since the high-resistance portions **14a** define the light emitting layer **14** on the respective anodes **13**, no leak current flows from one portion of the light emitting layer **14** to another, which prevents the occurrence of crosstalk and leads to an improvement on the clearness of displayed images.

### Third Embodiment

A third embodiment of the present invention will be discussed below with reference to FIGS. 8 through 10.

As shown in FIG. 8, each pixel **32** of an organic EL display apparatus **31** of the active matrix system has a thin film transistor (TFT) **33** as a pixel driving element. The TFT **33** is a planar type, and has an active layer comprised of a polycrystalline silicon film **34**. The TFT **33** preferably has an LDD (Lightly Doped Drain) structure. The polycrystalline silicon film **34** is formed on an insulator substrate **12**. A gate insulator film **35** is formed on the polycrystalline silicon film **34**, with a gate electrode **36** formed on the gate insulator film **35**. Defined on the polycrystalline silicon film **34** are a high-concentration drain region **37a**, a low-concentration drain region **37b**, a high-concentration source region **38a** and a low-concentration source region **38b**.

An interlayer insulator film **39** is formed on the TFTs **33**. The high-concentration drain region **37a** is connected to a drain electrode **41** via a contact hole **40** formed in the interlayer insulator film **39**. The high-concentration source region **38a** is connected to a source electrode **43** via a contact hole **42** formed in the interlayer insulator film **39**.

A planarizing insulator film **44** is formed on the individual electrodes **41** and **43** and the interlayer insulator film **39**. The source electrode **43** is connected to the associated

anode **13** via a contact hole **45** formed in the planarizing insulator film **44**.

Each of the insulator films **35** and **39** is preferably comprises a silicon oxide film, silicon nitride film or a silicon nitride oxide film. The planarizing insulator film **44** is preferably comprised of a silicon oxide film, a silicon nitride film, a silicon nitride oxide film, a silicate glass film, a SOG (Spin On Glass) film or a synthetic resin film (like a polyimide-based resin film, organic silica film or acrylic resin film). The electrodes **41** and **43** preferably comprise an aluminum alloy film.

A light emitting layer **14** is formed on the flattening insulator film **44**. The light emitting layer **14** includes a first hole transporting layer **50**, a second hole transporting layer **51**, a light emitting layer **52** and an electron transporting layer **53**. The layers **50–53** are preferably laminated, in order, on the insulator film **44**. The first hole transporting layer **50** is preferably formed of MTDATA (4,4',4"-tris(3-methylphenylphenylamino)triphenyl amine). The second hole transporting layer **51** is preferably formed of TPD (4,4'-bis(3-methylphenylphenylamino)biphenyl). The light emitting layer **52** is preferably formed of BeBq2 (10-benzo [h]quinolinol-beryllium complex) containing a quinacridone derivative. The electron transporting layer **53** is preferably formed of BeBq2. The individual layers **50–53**, the anodes **13** and the cathodes **16** form an organic EL element **17**.

In the organic EL element **17** according to the third embodiment, holes and electrons are recombined inside the light emitting layer **52**, generating light. The light goes outside via the anodes **13** and the insulator substrate **12**.

The hole transporting layers **50** and **51** both facilitate the injection of the holes from the anodes **13**. The electron transporting layer **53** facilitate the injection of the electrons from the cathodes **16**.

According to the third embodiment, as apparent from the above, the organic EL element **17** emits green light and has a high external quantum efficiency. A display panel **46** comprised of the organic EL element **17** has an improved luminous intensity.

The color of light emitted by the organic EL element **17** varies depending on the property of the organic compound that forms the light emitting layer **52**. It is preferable that OXD (oxadiazole) or AZM (azomethane-zinc complex) should be used for the emission of blue light, PYR (pyrazoline) is used for the emission of blue green light, Znq2 (8-quinolinol-zinc complex) should be used for the emission of yellow light, and ZnPr (porphyrin-zinc complex) should be used for the emission of red light.

Referring now to FIG. **9**, the circuit of the organic EL display apparatus **31** according to the third embodiment will be described. As shown, the organic EL display apparatus **31** includes the display panel **46**, a gate driver **55**, and a drain driver (data driver) **56**.

The display panel **46** has a plurality of gate lines (scan lines) G1, . . . , Gn, Gn+1, . . . , and Gm, a plurality of drain lines (data lines) D1, . . . , Dn, Dn+1, . . . , and Dm. The gate lines G1–Gm perpendicularly cross the respective drain lines D1–Dm, with pixels **32** located at the individual intersections. That is, the pixels **32** on the display panel **46** are arranged in a matrix form.

The gate driver **55**, connected to the individual gate lines G1–Gm, applies a gate signal (scan signal) to the gate lines G1–Gm. The drain driver **56**, connected to the individual drain lines D1–Dm, applies a data signal thereto. The drivers **55** and **56** comprise a peripheral driving circuit **57**. Each of the gate lines G1–Gm is comprised of the gate electrode **36**

of each TFT **33**. Each of the drain lines D1–Dm is comprised of the drain electrode **41** of each TFT **33**.

FIG. **10** shows an equivalent circuit diagram of the pixel **32**. A constant voltage Vcom is applied to the cathodes **16** of the organic EL element **17**, which acts as a capacitor. When a positive voltage is applied to the gate electrode **36** of the TFT **33** with a positive voltage applied to the gate line Gn, the TFT **33** is turned on. As a result, the capacitor of the organic EL element **17** is charged with a data signal applied to the drain line Dn, so that the data signal is written in the pixel **32**. The organic EL element **17** is driven by the data signal.

When a negative voltage is applied to the gate electrode **36** of the TFT **33** by a negative voltage applied to the gate line Gn, the TFT **33** is turned off. At this time, the data signal, applied to the drain line Dn, is held in the form of a charge in the capacitor of the organic EL element **17**. In this manner, an arbitrary data signal is held in each pixel **32** by inputting the data signal to each of the drain lines D1–Dm and controlling the voltage of each of the gate lines G1–Gm. The driving of the organic EL element **17** is maintained by the discharging of the capacitor until the TFT **33** is turned on again.

As mentioned in the "BACKGROUND OF THE INVENTION", when the number of gate lines (scan lines) is increased, the driving time assigned to one pixel **32** becomes shorter. According to the third embodiment, however, since a charge is stored between the anodes **13** and cathodes **16**, light emission is not interrupted, which prevents the contrast of an image to be displayed on the display panel **46** from decreasing. The organic EL display apparatus **31** of the active matrix system can, therefore, ensure higher quality display than the organic EL display apparatus of the simple matrix system.

In the third embodiment, each TFT **33** has an active layer comprised of the polycrystalline silicon film **34** and is formed into an LDD structure. It is therefore possible to increase the ON/OFF ratio of the TFT **33** and suppress the leak current in the OFF state, which leads to an improved quality of display images.

According to the third embodiment, the high-concentration source region **38a** is connected to the associated anode **13** via the source electrode **43** in order to provide a good ohmic contact between the high-concentration source region **38a** and the anode **13**. If the source electrode **43** is omitted, the high-concentration source region **38a**, comprised of the polycrystalline silicon film **34**, is directly connected to the anode **13** of ITO. Consequently, the hetero junction of the high-concentration source region **38a** and the associated anode **13** generates an energy gap associated with the band gap difference. Naturally, a good ohmic contact cannot be provided. Unless there is a good ohmic contact between the high-concentration source region **38a** and the associated anode **13**, the data signal applied to any of the drain lines D1–Dm cannot accurately be written in the associated pixel **42**, which lowers the image quality of the organic EL display apparatus **31**.

The drain regions **37a** and **37b** may be called source regions, and the drain electrode **41** may be called a source electrode, in accordance with the type of the TFT **33** (P-type or N-type). In this case, the drain lines D1–Dm are called source lines, and the drain driver **56** a source driver.

According to the third embodiment, either the first hole transporting layer **50** or the second hole transporting layer **51** may be omitted, or both may be omitted. Alternatively, the electron transporting layer **53** may be omitted. The

present invention can also be adapted to an organic EL element which has any of the aforescribed element structures.

The TFT 33 may be replaced with a TFT which has an SD (Single Drain) structure or a double gate structure, instead of the LDD structure. Further, the TFT 33 may be replaced with a TFT of a reversed planar type, a staggered type or a reverse staggered type, in place of the planar type. Furthermore, the TFT 33 may have an active layer which is comprised of an amorphous silicon film.

It should be apparent to those skilled in the art that the present invention may be embodied in many other specific forms without departing from the spirit or scope of the invention. Particularly, it should be understood that the invention may be embodied in the following forms.

(1) The present invention may be embodied in an organic EL display apparatus which has a plurality of anodes and one cathode. In this case, the single cathode may have a band-like shape or a planar shape whose area corresponds to the area of all of the anodes. Further, the present invention may be embodied in an organic EL display apparatus which has one anode and a plurality of cathodes. In this case, the single anode may have a band-like shape or a planar shape whose area corresponds to the area of all the cathodes. In any of the aforementioned structures, after a plurality of electrodes (cathodes or anodes) are formed on the insulator substrate 12, the electrodes are separated by a laser beam. After the light emitting layer 14 is formed on the electrodes, one electrode (anode or cathode) is formed on the light emitting layer 14.

(2) The present invention may be adapted to a transistor type organic EL display apparatus of the active matrix system, which uses bulk transistors as pixel driving elements, or a diode type organic EL display apparatus of the active matrix system. Diode type pixel driving elements include an MIM (Metal Insulator Metal) diode, ZnO (Zinc Oxide) varistor, MSI (Metal Semi-Insulator) diode, BTB (Back to Back) diode and RD (Ring Diode).

(3) Further, the present invention may be adapted to a display apparatus which uses inorganic EL elements.

(4) A plurality of light emitting layers 14 may be defined to run perpendicular to the individual anodes 13. Parts of the light emitting layers 14 which are sandwiched between the individual anodes 13 and the associated cathodes 16 may be defined or arranged in a matrix form. The matrix arrangement prevents the occurrence of a crosstalk.

Therefore, the present examples and embodiments are to be considered as illustrative and not restrictive and the invention is not to be limited to the details given herein, but may be modified within the scope and equivalence of the appended claims.

What is claimed is:

1. A display apparatus of an active matrix system comprising:

- a light emitting layer having a first surface and a second surface opposite to said first surface and arranged in a matrix form;
- a plurality of first electrodes opposing said first surface of said light emitting layer;
- a single second electrode opposing said second surface of said light emitting layer, wherein electroluminescence elements are formed at individual intersections of said first electrodes and said second electrode; and
- driving elements, arranged in association with said electroluminescence elements, for driving the associated electroluminescence elements.

2. The display apparatus according to claim 1, wherein said second electrode has a planar shape.

3. The display apparatus according to claim 1, wherein said driving elements comprise thin film transistors.

4. The display apparatus according to claim 1, wherein said light emitting layer comprises an organic compound.

5. The display apparatus according to claim 1, wherein said light emitting layer includes a first hole transporting layer of MTDATA, a second hole transporting layer of TPD, located on said first hole transporting layer, a light emitting layer of Beq2 containing a quinaclidone derivative, and an electron transporting layer of Beq2 located on said light emitting layer, wherein said second electrode comprises a magnesium-indium alloy.

6. The display apparatus according to claim 1, wherein said light emitting layer includes a light emitting layer, and at least a hole transporting layer or an electron transporting layer, located on said light emitting layer.

7. The display apparatus according to claim 6, wherein said hole transporting layer comprises a first hole transporting layer and a second hole transporting layer.

8. The display apparatus according to claim 1, further comprising an insulating layer arranged in the light emitting layer.

9. The display apparatus according to claim 1, further comprising high-resistance portions arranged in the light emitting layer.

10. The display apparatus according to claim 1, wherein the light emitting layer includes a layer for emitting light.

11. The display apparatus according to claim 1, wherein an area of said second electrode substantially corresponds to areas of all of said first electrodes.

12. The display apparatus according to claim 1, wherein said second electrode has a planar shape that substantially covers all of said second surface of said light emitting layer.

13. A display apparatus of an active matrix system comprising:

- a light emitting layer having a first surface and a second surface opposite to said first surface and defined into a plurality of regions;
- a plurality of first electrodes opposing said first surface of said light emitting layer;
- a single second electrode opposing said second surface of said light emitting layer, wherein electroluminescence elements are formed at individual intersections of said first electrodes and said second electrode; and
- driving elements, arranged in association with said electroluminescence elements, for driving the associated electroluminescence elements.

14. The display apparatus according to claim 13, wherein said second electrode has a planar shape.

15. The display apparatus according to claim 13, wherein said driving elements comprise thin film transistors.

16. The display apparatus according to claim 13, wherein said light emitting layer comprises an organic compound.

17. The display apparatus according to claim 13, wherein said light emitting layer includes a first hole transporting layer of MTDATA, a second hole transporting layer of TPD, located on said first hole transporting layer, a light emitting layer of Beq2 containing a quinaclidone derivative, and an electron transporting layer of Beq2 located on said light emitting layer, wherein said second electrode comprises a magnesium-indium alloy.

18. The display apparatus according to claim 13, wherein said light emitting layer includes a light emitting layer, and at least a hole transporting layer or an electron transporting layer, located on said light emitting layer.

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19. The display apparatus according to claim 18, wherein said hole transporting layer comprises a first hole transporting layer and a second hole transporting layer.

20. The display apparatus according to claim 13, further comprising an insulating layer arranged in a plurality of regions of the light emitting layer. 5

21. The display apparatus according to claim 13, further comprising high-resistance portions arranged in a plurality of second regions excluding the plurality of regions of the light emitting layer. 10

22. The display apparatus according to claim 13, wherein the light emitting layer includes a layer for emitting light.

23. A display apparatus of an active matrix system comprising:

a light emitting layer having a first surface and a second surface opposite to said first surface and arranged in a matrix form; 15

a plurality of first electrodes opposing said first surface of said light emitting layer;

a single second electrode opposing said second surface of said light emitting layer and used in common to said first electrodes, wherein electroluminescence elements are formed at individual intersections of said first electrodes and said second electrode; and 20

driving elements, arranged in association with said electroluminescence elements, for driving the associated electroluminescence elements. 25

24. The display apparatus according to claim 23, wherein said second electrode has a planar shape.

25. The display apparatus according to claim 23, wherein said driving elements comprise thin film transistors. 30

26. The display apparatus according to claim 23, wherein said light emitting layer comprises an organic compound.

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27. The display apparatus according to claim 23, wherein the light emitting layer includes a layer for emitting light.

28. A display apparatus of an active matrix system comprising:

a light emitting layer having a first surface and a second surface opposite to said first surface and defined into a plurality of regions;

a plurality of first electrodes opposing said first surface of said light emitting layer;

a single second electrode opposing said second surface of said light emitting layer and used in common to said first electrodes, wherein electroluminescence elements are formed at individual intersections of said first electrodes and said second electrode; and 10

driving elements, arranged in association with said electroluminescence elements, for driving the associated electroluminescence elements. 15

29. The display apparatus according to claim 28, wherein said second electrode has a planar shape. 20

30. The display apparatus according to claim 28, wherein said driving elements comprise thin film transistors.

31. The display apparatus according to claim 28, wherein said light emitting layer comprises an organic compound.

32. The display apparatus according to claim 28, wherein the light emitting layer includes a layer for emitting light. 25

33. The display apparatus according to claim 13, wherein an area of said second electrode substantially corresponds to areas of all of said first electrodes.

34. The display apparatus according to claim 13, wherein said second electrode has a planar shape that substantially covers all of said second surface of said light emitting layer. 30

\* \* \* \* \*

UNITED STATES PATENT AND TRADEMARK OFFICE  
**CERTIFICATE OF CORRECTION**

PATENT NO. : 6,642,544 B1  
DATED : July 5, 2000  
INVENTOR(S) : Hiroki Hamada

Page 1 of 1

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

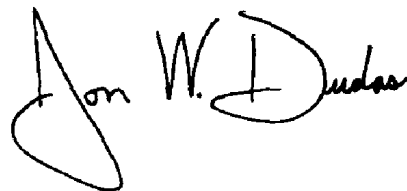
Title page, Item [54] and Column 1, line 2,

Title, should read:

-- **DISPLAY APPARATUS USING ELECTROLUMINESCENCE ELEMENTS  
AND METHOD OF MANUFACTURING THE SAME** --

Signed and Sealed this

Ninth Day of March, 2004

A handwritten signature in black ink, reading "Jon W. Dudas". The signature is stylized, with a large, looped initial "J" and a distinct "D".

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JON W. DUDAS  
*Acting Director of the United States Patent and Trademark Office*



专利名称(译)	使用电致发光元件的显示装置及其制造方法		
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[标]申请(专利权)人(译)	三洋电机株式会社		
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发明人	HAMADA, HIROKI KURIYAMA, HIROYUKI MATSUTA, SHIGEKI		
IPC分类号	H01L27/28 H01L27/32 H05B33/10 B23K26/364 G09F9/30 H01L51/50 H05B33/12 H05B33/14 H05B33/22 H01L33/00 H01J1/00		
CPC分类号	H01L27/3244 H01L27/3246 H01L27/3283 H01L51/0017 H01L27/3281 H01L51/0023		
代理机构(译)	SHERIDAN ROSS P.C.		
审查员(译)	SMITH , MATTHEW		
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外部链接	<a href="#">Espacenet</a> <a href="#">USPTO</a>		

# 摘要(译)

具有电致发光 ( EL ) 元件的显示装置包括用于产生光的发光层。高能激光束照射在发光元件层上以限定发光层的多个区域。多个第一电极在发光层的第一表面上大致彼此平行地布置，并且多个第二电极在发光的第二相对表面上大致彼此平行并且垂直于第一电极布置。。 EL 元件形成在第一和第二电极的交叉处。

